

IN THE CLAIMS:

The listing of claims will replace all prior versions, and listings, of claims in the application:

1. (Previously Presented) A method of positioning an object at a required position on an object table in a lithographic projection apparatus, comprising:
placing an object at a first position on a first object table;
measuring a displacement between the first position of the object and a required position of the object;
removing the object from the first object table;
moving the object and the first object table relatively to each other by substantially the said displacement, in a direction substantially parallel to the plane of the table; and
placing the object at substantially the required position on the first object table.
2. (Currently Amended) A method according to claim 1, wherein said measuring comprises aligning a first mark on the object to a second, ~~reference~~ mark.
3. (Previously Presented) A method according to claim 2, wherein said second mark is located on the one of the first object table and a second object table.
4. (Previously Presented) A method according to claim 1 wherein a mask is held by the first object table.
5. (Previously Presented) A method according to claim 2, wherein said second mark is located on one of a mask and a substrate.
6. (Previously Presented) A method according to claim 1, wherein said measuring is accomplished using imaging means to determine the displacement between the first position of the object and the required position of the object.
7. (Previously Presented) A method according to claim 1, wherein said measuring comprises processing information about the first position of the object, together with information regarding the required position of the object to determine said displacement.

8. (Original) A method according to claim 1, wherein said displacement deviation is rotational around an axis perpendicular to the plane of the table.

9. (Original) A method according to claim 1, wherein said object is held in place using a vacuum generating surface.

10. (Original) A method according to any of the proceeding claims wherein the radiation system comprises a radiation source.

11. (Previously Presented) A method of positioning a substrate at a required position on a substrate table, said method comprising:
placing the substrate at a first position on the table;
measuring a displacement between the first position of the substrate and a required position of the substrate;
removing the substrate from the table;
moving the substrate and the table relatively to each other by substantially the said displacement, in a direction substantially parallel to the plane of the table; and
placing the substrate at substantially the required position on the table.